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FABRICATION OF INTERMETALLIC COATINGS FOR ELECTRICAL INSULATION AND CORROSION RESISTANCE ON HIGH-TEMPERATURE ALLOYS

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Abstract

Several intermetallic films were applied to high-temperature alloys (vanadium alloys and 304 and 316 stainless steels) to provide electrical insulation and corrosion resistance. Alloy grain-growth behavior at 1000°C for the V-5Cr-5Ti alloy was investigated to determine stability of the alloy substrate during coating formation by chemical vapor deposition (CVD) or metallic vapor processes at 800-850°C. Film layers were examined by optical and scanning electron microscopy and by electron-energy-dispersive and X-ray diffraction analysis; they were also tested for electrical resistivity and corrosion resistance. The results elucidated the nature of the coatings, which provided both electrical insulation and high-temperature corrosion protection.

Introduction

Corrosion resistance of structural materials and magnetohydrodynamic (MHD) force and its influence on thermal hydraulics are major concerns in the design of a liquid-metal cooling system for a first-wall/blanket in a magnetic fusion reactor (MFR).^{1,2} Vanadium and V-base alloys (V-Ti or V-Ti-Cr) are leading candidate materials for structural applications in a fusion reactor.³ The objective of this study is to develop stable corrosion-resistant coatings, as well as insulator coatings, at the liquid-metal/structural-material interface. Previous studies focused on in-situ formation of AlN on as-received and prealuminized V-alloys in liquid-Li environments.^{4,5} Subsequent work addressed in-situ formation of CaO in a liquid-Li environment because the electrical resistivity of CaO is 10,000 times higher than that of AlN, and because CaO has a high thermodynamic stability in liquid Li among the available insulator candidates (i.e., CaO, Y₂O₃, BeO, MgO, MgAl₂O₄, Y₃Al₂O₁₂, etc.).⁵⁻⁷ The coatings should be formable on various shapes such as the inside of tubes or irregular shapes to prevent adverse currents that are generated by MHD forces from passing through the structural walls.

The coatings could also improve general corrosion resistance and act as a diffusion barrier for hydrogen isotopes, viz., deuterium and tritium.

Approaches for Insulator Coating Development

Several experimental steps were employed to develop insulator coatings on V-based alloys, namely (a) screening of selected electrical insulators in liquid Li based on thermodynamic stability, electrical resistivity, coefficients of thermal expansion (CTE), and diffusion coefficients of cations and anions within the coating layer; (b) liquid-Li compatibility tests for candidate electrical insulators;^{5,6} and (c) methods of in-situ fabrication of intermetallic coatings in liquid Li by conversion of an intermetallic layer to an electrical insulator coating in a controlled environment. Failure (cracking or spallation) and self-healing characteristics of the coating layer are also important in MFR applications. This paper presents results on compatibility of candidate insulators with liquid Li and fabrication of intermetallic coatings on V-5%Cr-5%Ti.

Solid-State Interactions: Bonding of AlN and Metal/Alloy Substrates

Solid-state interactions between AlN and several metals and alloys (viz., V, V-5%Cr-5%Ti, Ti, and Type 316 stainless steel) were investigated. Sintered discs of Y₂O₃-enriched AlN (12.7 x 50 x 9 mm) were obtained from the Ceramics Section at Argonne National Laboratory. ICP-spectrochemical analysis of the AlN samples indicated the following composition (in wt.%): As < 0.05, Ba = 0.005, Be < 0.001, Ca = 0.54, Co < 0.002, Cr < 0.002, Cu = 0.006, Fe = 0.015, Y = 3.77, Y₂O₃ = 4.79, Mg = 0.004, Mn < 0.001, Ni = 0.002, Pb < 0.02, Sb < 0.05, Sn < 0.02, Sr < 0.001, Ti = 0.022, V < 0.002, Zn < 0.002, Zr < 0.002, and Te < 0.05. The discs were cut into pieces measuring 12.7 x 12.7 x 2.7 mm and ground flat on Struers 4000 silicon carbide paper. The discs were then ultrasonically cleaned in isopropyl alcohol. A disc of each metal or alloy was placed between two AlN discs and the entire stack was

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placed in a furnace. A compressive force was applied to the stack by using a 120°-three-spring-loaded alumina rod on the top of the stack. A detailed description of the apparatus is given elsewhere.⁷ The AlN/alloy stack was annealed in a furnace at 900°C for 129 h in flowing 3%H₂-N₂. After cooling, the specimen stack was examined for indications of strong bonding between AlN/alloy substrates. Interfaces between the alloys and AlN were examined by SEM/EDS to determine diffusion profiles of various elements. Results for the diffusion couples are given below.

V/AlN: V diffused into AlN, but a bond was not formed and VN was not detected. The absence of a good bond and no interdiffusion of N are not conducive to the development of an adherent coating by a high-temperature process. In this case, a low-temperature physical vapor deposition (PVD) technique could be tried, but if the operating temperature increases or the service time is very long, the base metal (V) could be degraded by formation of vacancies at the metal/AlN interface, grain boundaries, and dislocations. Eventually, vacancies would coagulate to form voids within the V substrate, which could lead to debonding of the coating.

Ti/AlN: Ti did not bond with AlN but a thin layer formed at the Ti/AlN interface. This is indicative of a Ti_xN_y phase, and some diffusion of N into Ti was evident. Bonding of AlN/Ti_xN_y exhibited sintering-like behavior; however, Ti_xN_y was detached from Ti in some areas, which indicates outward diffusion of Ti during formation of Ti_xN_y. These processes are shown in Fig. 1.

V-5Cr-5Ti/AlN: Neither V, Ti, nor the V alloy bonded with AlN. Minimal information was obtained because no bonding occurred. Coarsening of grains in V-5Cr-5Ti at the alloy/AlN interface was observed, and may have been accelerated by applied pressure.

Type 316 Stainless Steel/AlN: Reaction occurred between a thin oxide scale (Cr₂O₃) on the Type 316 stainless steel and AlN to form Al-Cr-O. AlN particles were found on the surface of the steel, which suggests that a strong bond could be produced in this couple. Dissolved oxygen in the steel transferred to the surface and reacted with AlN to form Al-O-N at the interface. The predicted products from this diffusion couple are AlN/Al-O-N/Al-Cr-O/SS after long-term exposure. Strong bonding formation between Type 316 stainless steel/AlN interface was observed. This couple is applicable to the development of insulator coatings because the ohmic resistance of Al-O-N phase was higher than expected. In the same vein, we may pursue the interaction of oxygen-charged V-5Cr-5Ti alloys with AlN to produce a V-5Cr-5Ti-(O)/Al-O-N/AlN couple, which may also reveal enhanced ohmic

resistance. Preparation of oxygen-charged in V-5Cr-5Ti was described previously.⁸

Diffusion Approach for In-Situ Formation of Insulator Coatings in Liquid Li

Ionic diffusion (cation, anion, or both) within the coating must be considered during formation, as should long-term exposure of insulator coatings in liquid-Li environments.

Outward Cation or Anion Diffusion from Alloys or Ceramic Substrates: In this case, a metal ion (cation) or anion leaves the substrate and migrates to the scale/liquid-metal interface, and a vacancy may be produced at a grain boundary, dislocation, or other active defect area within the substrate (Fig. 2). The consequences of predominantly outward diffusing species at the metal/coating interface are vacancy formation and coalescence (void formation) near the interface, and reduction in the bond strength between coating/substrate. However, if the chemical potential gradient at the coating/substrate is relatively small at elevated temperatures, void formation may not occur. In general, outward cation or anion diffusion from alloys or ceramic substrates should be avoided.

Inward Diffusion via Insulator Layer: If anions of O, N, (or C) within the coating layer diffuse inward toward the alloy, insulator-layer growth occurs at the alloy/coating interface. However, diffusion of cations from metal atoms in the liquid environment must also be considered.

Grain-Growth Behavior of V-5%Cr-5%Ti

In coatings produced by high-temperature processes such as CVD or thermally grown layers, grain growth and changes in morphology of the alloy influence the coating properties.⁸ Even though the CTEs of the substrate and coating layer are similar in magnitude, adherent coatings may not form because of inadequate stabilization of alloy substrate. This is more prevalent in the case of brittle ceramic or intermetallic coatings on metallic substrates because of diffusion-related phenomena in the metal (e.g., grain growth) rather than in the ceramic at high processing temperatures. For high-temperature alloys, viable coatings require alloy stabilization before coating application;⁹ otherwise, the coating layers tend to spall during high-temperature operation because of grain growth or other morphological changes. In the case of Fe-Cr steels, a small amount of Y (≈0.3 wt.%) in the alloy inhibits grain growth.⁹

The V-5%Cr-5%Ti specimens were wrapped in Ta foil, sealed in quartz capsules in vacuo to avoid Si or O contamination, and annealed for 0.3–61.3 h at 1000°C. Figures 3 and 4 show grain morphology and change in

Figure 1: Schematic diagram of solid-state reaction steps at Ti/AlN interface.

Figure 2: Coating layer formation by different diffusion profiles.

Figure 3: SEM photomicrographs of V-5%Cr-5%Ti specimens after annealing several times at 1000°C in grain-growth experiments.

Figure 4: Increase in grain size (Δd , μm) from as-received value ($7 \mu\text{m}$) for V-5Cr-5Ti specimens as a function of time at 1000°C .

grain diameter of V-5Cr-5Ti as a function of time, respectively. At 1000°C , grain growth decreases rapidly after ~ 2.5 h; the grain size of a specimen annealed for 24 h is almost the same as the one annealed for 2.5 h. The increase in grain size, Δd , was $7 \mu\text{m}$ for an initial average grain size of $7 \mu\text{m}$. Grain-growth behavior at 1000°C in terms of $\log \Delta d$ versus $\log t$ can be represented by

$$\log \Delta d = 0.58 + \log t^{0.53}, \quad (1)$$

where the ~ 0.5 exponent of time is indicative of a diffusion mechanism. Based on these results, we expect that grain growth will not have a significant effect on high-temperature coating by processes such as CVD, pack cementation, or PVD.

Formation of Intermetallic Coatings on High-Temperature Alloys

Various intermetallic and insulator layers were developed by different methods, namely, CVD, high-temperature PVD, ion-beam-assisted deposition (IBAD), and exposure of specimens to liquid Li containing dissolved metallic solutes (Al, Be, Mg, Si, Ca, Pt, Y, and Cr) to form coatings by chemical reaction with constituents in various metals and alloys (Ti, V-5Cr-5Ti, V-Ti, Types of 304 and 316 stainless steel, Fe-25Cr with 0.3 Y or 6 Al). Most of the solutes in Li were chosen on the basis of thermodynamic stability of their metal oxides or nitrides in Li, as well as on results of compatibility screening tests for ceramic materials in Li.

Chemical Vapor Deposition

Aluminide and AlN Coatings: Aluminide coatings that form on structural alloys during exposure to liquid Li

that contained dissolved Al suggest a means for producing stable electrical insulator layers, such as AlN, by subsequent nitration of the intermetallic layer in the liquid-metal environment.⁷ The formation of several aluminides (V_xAl_y) that contain >40 – 50 at.% Al on V-base alloys can be predicted from the V-Al phase diagram shown in Fig. 5.^{10,11} These phase relationships are the basis for the formation of aluminide coatings on V and its alloys. Aluminide coatings were produced on the alloys by CVD at 800 – 850°C with trimethyl aluminum ($(\text{CH}_3)_3\text{Al}$) used as the source of Al to be diffused/reacted on the sample surfaces. In this study, atmospheric-pressure CVD was used because of its utility for engineering applications. Figure 6 is a schematic diagram of the CVD apparatus. The $(\text{CH}_3)_3\text{Al}$ vapor was aspirated by a 3% H_2 -Ar carrier gas with impurity oxygen and carried via a Ta tube to the high-temperature zone, where the vapor decomposed and reacted with the specimens. The reaction for the formation of aluminides is

and the ΔG° range for the reaction is -4 to -5 kcal/mole (Fig. 7).

This process was followed by mixing of NH_3 into the gas stream to convert the aluminide to an AlN coating according to the reaction

where N represents nitrogen activity in the gas phase or dissolved in liquid Li. The free energy of formation of AlN is -45.94 kcal/mole; therefore, the ΔG° for the reaction in Eq. (3) is -40.94 kcal/mole at 700 K. This

Figure 5: Al-V binary phase diagram.

Figure 6: Schematic of CVD apparatus.

Figure 7: Gibbs free energy of formation for various inter-metallic compounds in Al-V system as a function of temperature.

reaction will occur spontaneously, and the rate-determining step will be ionic diffusion through the nitride layer. Residual V formed during the reaction will either redistribute within Al_3V or AlN will become enriched in V, depending on the direction of V diffusion and the thermodynamic stability of V_2N near the $\text{Al}_3\text{V}/\text{AlN}$ interface. Because of the high thermodynamic stability of TiN , formation of this phase on aluminided V-5%Cr-5%Ti is also a possibility.*

Figure 7 (a) is an SEM photomicrograph of an intermetallic vanadium aluminide coating on a V-5Cr-5Ti substrate. The chemical composition of the coating surface by electron-energy-dispersive spectroscopy (EDS) is as follows:

Al	61.34 at.%	(45.72 wt.%)
V	33.57 at.%	(47.23 wt.%)
Cr	2.72 at.%	(3.91 wt.%)
Ti	2.37 at.%	(3.13 wt.%)

Based on these compositions and the V-Al binary phase diagram (Fig. 1), the composition of the intermetallic phase at the surface lies between Al_3V and Al_8V_5 . When we consider the free energy of formation of Al-V intermetallic phases (Fig. 7), the Al_3V phase should form because of its greater stability, but at high temperatures (850°C, 1123K) a mixture of Al_3V and Al_8V_5 could arise due to the similar magnitudes of the free energies of formation. However, if Al concentration is not high enough (e.g., >40 at.%), V-Al intermetallic phases will not form at the surface and Al will only diffuse into the bcc sublattice of V according to the phase diagram (Fig. 5). Based on our previous work,¹² Al_3V was prevalent on various V-Cr-Ti alloys.

Figure 8 (a) shows an SEM photomicrograph and EDS spectra of an aluminide surface on V-5%Cr-5%Ti at 850°C, and Fig. 8(b) shows similar information for an AlN surface formed at 800°C. The Ta tube that carried the gas into the high-temperature zone was also analyzed. Figure 9 shows the Ta-Al intermetallic and AlN coatings on the inner surface of the tube. CVD in which $\text{AlCl}_3/\text{NH}_3$ is the source of Al may not be applicable for many materials because of Cl-induced corrosion. Figure 10 is an SEM photomicrograph of a CVD coating on V-5%Cr-5%Ti at 850°C where AlCl_3 was used. When vanadium chloride compounds form during the coating process, they tend to spall and prevent the formation of an adherent AlN layer at the surface.

*When we exposed prealuminide V-5Cr-5Ti to liquid Li containing 100-200 ppm N, TiN grew outward between the aluminide grains.

Al_2O_3 Coatings on Stainless Steels in Air

Low rates of elemental diffusion and electron transport in Al_2O_3 are desirable properties for high-temperature corrosion-resistant coatings. However, benefits from these properties for high-temperature coating applications are rather limited because crack-free Al_2O_3 coatings are extremely difficult to fabricate. In this study, we have had some success in forming Al_2O_3 coatings on Types 304 and 316 stainless steel. Coatings were produced by growing an intermetallic aluminide layer (FeAl) on the steels in liquid Li containing 4-5 wt.% dissolved Al, followed by oxidation of the aluminide layer in air at 1000°C. Figure 11 shows circular and longitudinal cross sections of an 0.5-in.-diameter Type 304 stainless steel tube in which the aluminide coating layer on the inside surface was oxidized in air for 72 h at 1000°C. To determine the minimum required Al content of the steel to form an Al_2O_3 coating layer, samples of aluminided steel tube were sectioned and polished and an Al depth profile was measured by EDS (detection limit of ~1 at.%). After oxidation, an Al spectrum from EDS analysis indicated a continuous Al_2O_3 coating layer had formed. Figure 12 shows Al_2O_3 coating layers formed on the inside of other Type 304 stainless steel tubes.

Based on our previous experience, most Al_2O_3 coating layers formed on Fe-Cr-Al alloys contained numerous cracks, mainly due to mismatch of the CTE ($\approx 8 \times 10^{-6}/\text{K}$ for Al_2O_3 and $\approx 17 \times 10^{-6}/\text{K}$ for stainless steel). We believe that Li (130 ppm) in the aluminide layer that formed in liquid Li containing Al plays a role in accommodating thermal stresses during Al_2O_3 growth and cooling because of fast diffusion of Li^+ ions due to their small size.

High-Temperature Metallic Mg Vapor Deposition of MgO Coating

MgO is another potential candidate for an insulator coating in a liquid-Li blanket of an MFR. An MgO coating could be applied by various components by vapor deposition because metallic Mg has a high vapor pressure at elevated temperatures. This coating method was investigated with the apparatus similar to that shown in shown in Fig. 6. Mg vapor was generated in a high-temperature Knudsen cell located at the bottom of the stainless steel chamber, which provided a homogeneous source of Mg vapor. Mg was contained in a tungsten or Type 304 stainless steel boat and covered with a plate containing a small hole (≈ 1.5 -mm-diameter pinhole). Sublimation of Mg in a relatively low vacuum of 10^{-3} to 10^{-4} torr, in which O_2 was present as an impurity, enabled the formation of MgO clusters by oxidation of Mg vapor inside the chamber. After coating the V-5Cr-5Ti specimens at 800°C, the system was cooled to room temperature by

Figure 11: Al_2O_3 coating by air oxidation of 0.5-in.-diameter aluminided Type 304 stainless steel tube at 1000°C.

Figure 12. Al_2O_3 coating by air oxidation of aluminided Type 304 stainless steel tube at 1000°C: (a) cross section of tube, (b) longitudinal cross section of tube, (c) polished region near outside surface of tube to investigate grain-boundary penetration of oxygen, (d) view of extended scale of (b), (e) view of extended scale of (c), and (f) details of (e) by back-scattered electron image.

Figure 8: SEM/EDS photomicrographs of
(a) aluminide coating on V-5Cr-5Ti, and
(b) Al/AlN coating.

Figure 9: SEM photomicrograph of (a) aluminide coating, and (b) Al/AlN coating on inside surface of Ta tubes.

Figure 10: AlN coating produced by CVD with $\text{AlCl}_3/\text{NH}_3$ showing heavy spallation (light area; V-Cl compound) and V-Al-N coating (dark area).

purging with Ar (99.999%). The ohmic resistance of the coatings was measured at room temperature and the coatings were evaluated by SEM/EDS. Figure 13 shows a typical MgO coating on V-5Cr-5Ti (a), and its EDS spectrum is shown in Fig. 13 (b). The measured two-point contact resistance at room temperature is $>10^{12} \Omega$. This coating technique could be extended to other oxides, e.g., CaO, BeO, MgAl_2O_4 , $\text{Y}_3\text{Al}_2\text{O}_{12}$.

Figure 13: (a) MgO coating on V-5Cr-5Ti and (b) EDS of (a).

Conclusions

High-temperature couples between AlN and V-alloys, Ti, and Types 304 and 316 stainless steel showed different interface bonding behaviors. Basically, V-alloy/AlN couples did not bond. In the case of Ti/AlN, TiN formed at the interface, but the bonding strength was too low and separation occurred at the Ti/TiN interface. Strong bonds were obtained between AlN and the stainless steels, but mismatch in the thermal expansion coefficients caused fracture in the relatively thick AlN layer above the alloy/AlN interface.

Intermetallic films were prepared on V-alloys and Types 304 and 316 stainless steel by chemical vapor deposition, high-temperature metallic vapor deposition, and liquid-metal processing in the temperature range of 800-850°C. The films were examined by optical and scanning electron microscopy and by electron-energy-dispersive and X-ray diffraction analysis. Aluminide films containing >45 wt.% Al and AlN were produced on V-alloys by CVD. The

aluminide films on Types 304 and 316 stainless steel were converted to Al_2O_3 by oxidation in air at high temperature. The results elucidated the nature of the coatings, which provided both electrical insulation and high-temperature corrosion protection.

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